## EE4C10 Analog Circuit Design Fundamentals

#### Homework Assignment I

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#### Problem 1

For  $I_D = 40 \mu A$ :

$$I_D = \frac{1.8V - V_D}{R}$$
 
$$V_D = 1.8V - I_D R$$
 
$$V_D = 1.0V$$

Saturation region:

$$V_{GS} = 1.0V > V_{TH}$$
  
$$V_{GS} - V_{TH} = 0.4V < V_{DS}$$

1. 
$$\lambda = 0V^{-1}$$

$$I_D = \frac{\mu_n C_{OX}}{2} \frac{W}{L} (V_{GS} - V_{TH})^2$$

$$L = \frac{\mu_n C_{OX}}{2} \frac{W}{I_D} (V_{GS} - V_{TH})^2$$

$$\underline{L} = 0.39 \mu m$$

2.  $\lambda = 0.06V^{-1}$ 

$$I_{D} = \frac{\mu_{n} C_{OX}}{2} \frac{W}{L} (V_{GS} - V_{TH})^{2} (1 + \lambda V_{DS})$$

$$L = \frac{\mu_{n} C_{OX}}{2} \frac{W}{I_{D}} (V_{GS} - V_{TH})^{2} (1 + \lambda V_{DS})$$

$$\underline{L} = 0.41 \mu m$$

#### Problem 2

1. Bulk of the transistors are connected to the source,  $V_B = V_S$ 

$$V_{TH} = V_{TH0} + \gamma(\sqrt{2\varphi_F + V_{BS}} - \sqrt{|2\varphi_F|})$$
  
$$V_{TH} = V_{TH0} = 0.33V$$

(a) Transistor M<sub>1</sub>

$$V_{SG} = 2.5V - 1.7V = 0.8V$$

$$I_D = \frac{\mu_p C_{OX}}{2} \frac{W}{L} (V_{SG} - V_{TH})^2$$

$$W = \frac{2LI_D}{\mu_p C_{OX}} \frac{1}{(V_{SG} - V_{TH})^2}$$

$$W_1 = 2.72 \mu m$$

(b) Transistor M<sub>2</sub>

$$V_{SG} = 1.7V - 1V = 0.7V$$

$$W = \frac{2LI_D}{\mu_p C_{OX}} \frac{1}{(V_{SG} - V_{TH})^2}$$
$$W_2 = 4.38 \mu m$$

(c) Transistor M<sub>3</sub>

$$V_{SG} = 1V$$

$$W = \frac{2LI_D}{\mu_p C_{OX}} \frac{1}{(V_{SG} - V_{TH})^2}$$

$$W_3 = 1.37 \mu m$$

- 2. Bulk terminals are attached to the  $V_{DD}$ ,  $V_B = V_{DD}$ .
  - (a) Transistor M<sub>1</sub>

$$V_{BS} = 2.5V - 2.5V = 0V$$

$$V_{TH} = V_{TH0} + \gamma(\sqrt{2\varphi_F + V_{BS}} - \sqrt{|2\varphi_F|})$$
  
$$V_{TH} = V_{TH0} = 0.33V$$

$$W = \frac{2LI_D}{\mu_p C_{OX}} \frac{1}{(V_{SG} - V_{TH})^2}$$
 
$$W_1 = 2.72 \mu m$$

(b) Transistor M<sub>2</sub>

$$V_{BS} = 2.5V - 1.7V = 0.8V$$

$$V_{TH} = V_{TH0} + \gamma(\sqrt{2\varphi_F + V_{BS}} - \sqrt{|2\varphi_F|})$$
  
$$V_{TH} = V_{TH0} = 0.43V$$

$$W = \frac{2LI_D}{\mu_p C_{OX}} \frac{1}{(V_{SG} - V_{TH})^2}$$
 
$$W_2 = 8.23 \mu m$$

(c) Transistor M<sub>3</sub>

$$V_{BS} = 2.5V - 1.0V = 1.5V$$

$$V_{TH} = V_{TH0} + \gamma(\sqrt{2\varphi_F + V_{BS}} - \sqrt{|2\varphi_F|})$$
  
$$V_{TH} = V_{TH0} = 0.49V$$

$$W = \frac{2LI_D}{\mu_p C_{OX}} \frac{1}{(V_{SG} - V_{TH})^2}$$
 
$$W_3 = 2.31 \mu m$$

- 1. Testbench and  $I_{\rm D}\text{-}V_{\rm GS}$  characteristics of NMOS and PMOS
  - (a) NMOS
    - i. Testbench

# .lib 'C:\Program Files\LTC\LTspiceXVII\lib\cmp\log018.l' TT .dc VGS 0 1.8 0.001

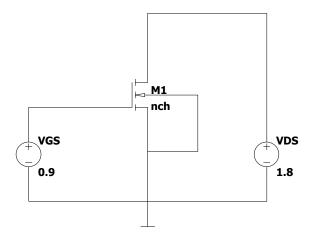


Figure 1: NMOS Testbench

#### ii. $I_{\rm D}\text{-}V_{\rm GS}$

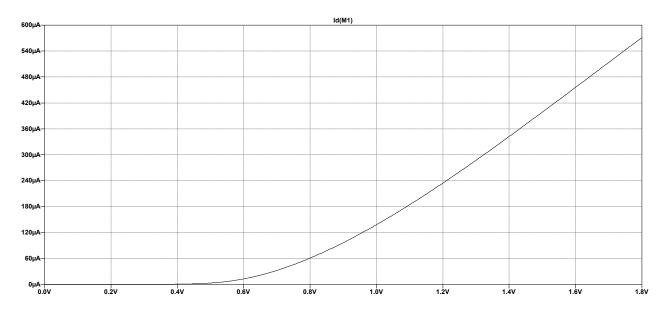


Figure 2: NMOS  $\rm I_D\text{-}V_{GS}$ 

#### (b) PMOS

i. Testbench

## .lib 'C:\Program Files\LTC\LTspiceXVII\lib\cmp\log018.l' TT .dc VGS -1.8 0 0.001

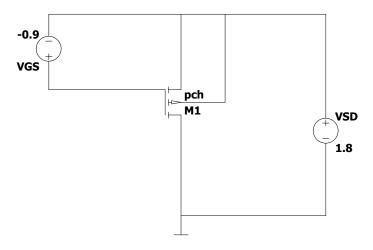


Figure 3: PMOS Testbench

#### ii. $I_S$ - $V_{GS}$

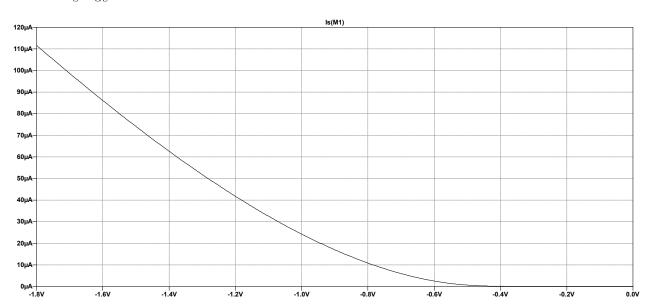


Figure 4: PMOS  $I_S$ - $V_{GS}$ 

#### 2. $\mu_{n(p)}C_{OX}$ and $V_{THn(p)}$

Assuming that channel length modulation is negligible,  $V_{THn}$  for NMOS can be derived from the following relation:

$$I_D = \frac{\mu_n C_{ox}}{2} \frac{W}{L} (V_{GS} - V_{THn})^2$$

$$\frac{2I_D}{\mu_n C_{ox}} \frac{L}{W} = (V_{GS} - V_{THn})^2$$

$$\sqrt{\frac{2I_D}{\mu_n C_{ox}} \frac{L}{W}} = V_{GS} - V_{THn}$$

 $V_{THn}$  is the x-axis intercept when the saturation region is extrapolated. In the case of PMOS, the relation becomes:

$$\sqrt{\frac{2I_S}{\mu_p C_{ox}} \frac{L}{W}} = V_{SG} - V_{THp}$$

For deriving  $\mu_n C_{OX}$ , since  $V_{THn(p)}$  is constant at specific temperatures. Differentiating both sides with respect to

 $V_{\mathrm{GS}(\mathrm{SG})}$  will give:

$$\frac{d}{dV_{GS}} \sqrt{\frac{2I_D}{\mu_n C_{ox}} \frac{L}{W}} = \frac{d}{dV_{GS}} (V_{GS} - V_{THn})$$

$$\frac{1}{2} \frac{dI_D}{dV_{GS}} \sqrt{\frac{2}{I_D \mu_n C_{ox}} \frac{L}{W}} = 1$$

$$\sqrt{\mu_n C_{ox}} = \frac{1}{2} \frac{dI_D}{dV_{GS}} \sqrt{\frac{2}{I_D} \frac{L}{W}}$$

$$\mu_n C_{ox} = \frac{1}{2} \frac{L}{W} \frac{1}{I_D} (\frac{dI_D}{dV_{GS}})^2$$

$$\mu_n C_{ox} = \frac{1}{6I_D} (\frac{dI_D}{dV_{GS}})^2$$

In the case for PMOS, the relation becomes:

$$\mu_p C_{ox} = \frac{1}{6I_S} \left(\frac{dI_S}{dV_{SG}}\right)^2$$

(a) NMOS

i. 
$$\mu_n C_{OX} = 306 \mu A V^{-2}$$

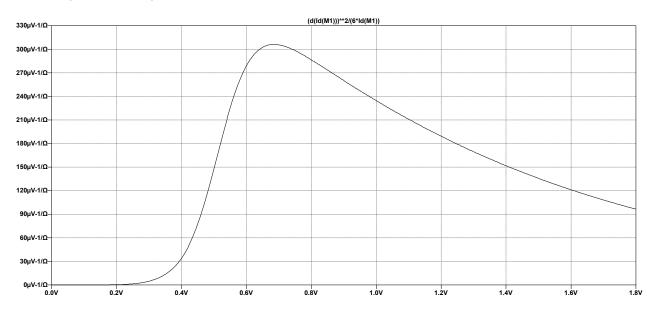


Figure 5: NMOS  $\mu_{\rm n} C_{\rm OX}\text{-}V_{\rm GS}$ 

ii.  $V_{THn} = 0.44V$ 

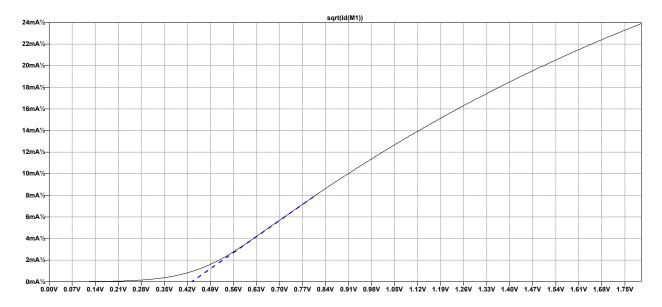


Figure 6: NMOS  $\sqrt{I_D} - V_{GS}$ 

#### (b) PMOS

i. 
$$\mu_p C_{OX} = 294 \mu A V^{-2}$$

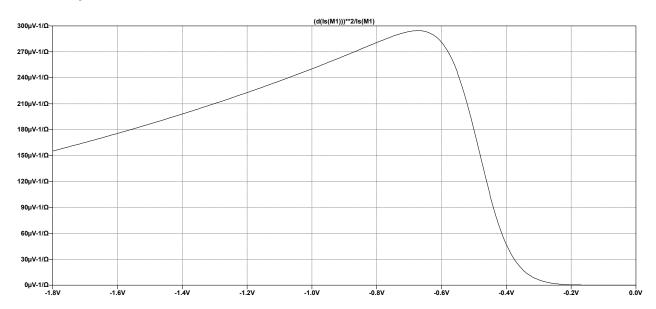


Figure 7: PMOS  $\mu_{\rm p} {\rm C_{OX}\text{-}V_{GS}}$ 

ii. 
$$V_{THp} = -0.42V$$

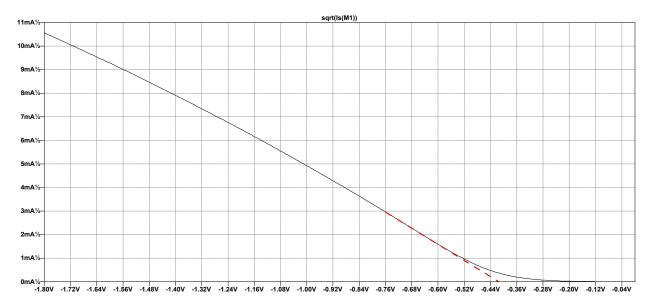


Figure 8: PMOS  $\sqrt{I_S} - V_{GS}$ 

- 1. Testbench and  $\rm I_D\text{-}V_{DS}$  characteristics of NMOS and PMOS
  - (a) NMOS
    - i. Testbench

# .lib 'C:\Program Files\LTC\LTspiceXVII\lib\cmp\log018.l' TT .dc VDS 0 1.8 0.001

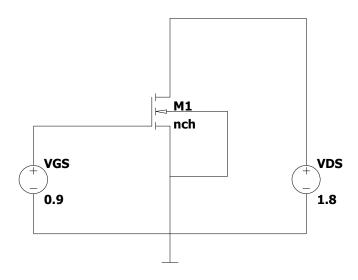


Figure 9: NMOS Testbench

ii.  $I_D$ - $V_{DS}$  characteristics

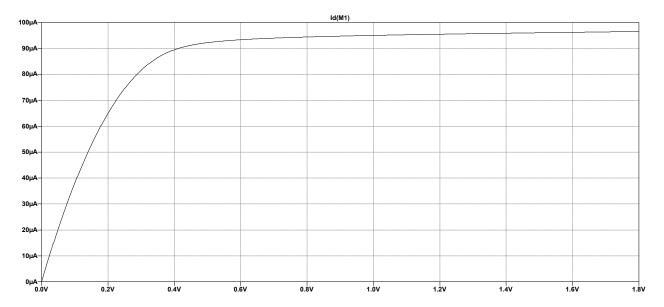


Figure 10: NMOS  $\rm I_D\text{-}V_{DS}$ 

#### (b) PMOS

i. Testbench

## .lib 'C:\Program Files\LTC\LTspiceXVII\lib\cmp\log018.l' TT .dc VDS -1.8 0 0.001

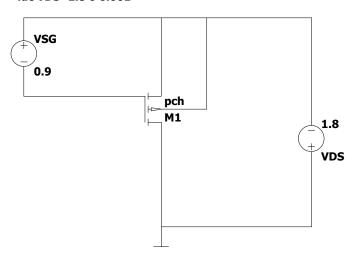


Figure 11: PMOS Testbench

ii.  $I_{\rm S}\text{-}V_{\rm DS}$  characteristics

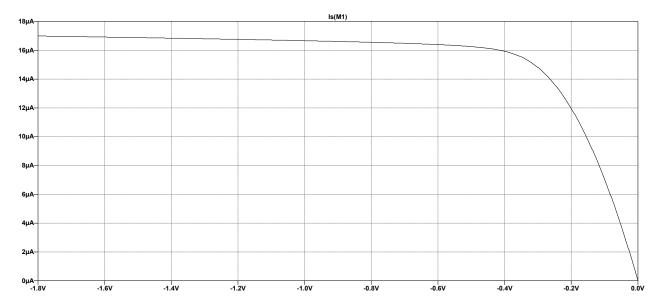


Figure 12: PMOS  $\rm I_S\text{-}V_{DS}$ 

#### 2. $\lambda_{n(p)}$

Drain current characteristics for NMOS under saturation conditions:

$$I_{D} = \frac{\mu_{n} C_{ox}}{2} \frac{W}{L} (V_{GS} - V_{TH})^{2} (1 + \lambda_{n} V_{DS})$$

Differentiating both side with respect to  $V_{\rm DS}$ .

$$\frac{dI_D}{dV_{DS}} = \frac{d}{dV_{DS}} \left( \frac{\mu_n C_{ox}}{2} \frac{W}{L} (V_{GS} - V_{TH})^2 (1 + \lambda_n V_{DS}) \right)$$

$$\frac{dI_D}{dV_{DS}} = \frac{\mu_n C_{ox}}{2} \frac{W}{L} (V_{GS} - V_{TH})^2 \lambda_n$$

Assuming that the body-effect is small:

$$I_D \approx \frac{\mu_n C_{ox}}{2} \frac{W}{L} (V_{GS} - V_{TH})^2$$

$$\frac{dI_D}{dV_{DS}} \approx I_D \lambda_n$$
 
$$\lambda_n \approx \frac{1}{I_D} \frac{dI_D}{dV_{DS}}$$

In the case of PMOS:

$$\lambda_p pprox rac{1}{I_S} rac{dI_S}{dV_{SD}}$$

(a) 
$$\lambda_n = 0.18V^{-1}$$

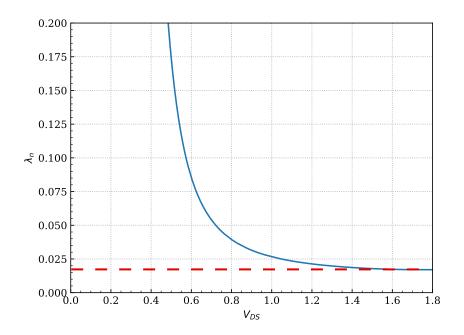


Figure 13: NMOS  $\lambda_n - V_{DS}$ 

(b) 
$$\lambda_p = -0.022V^{-1}$$

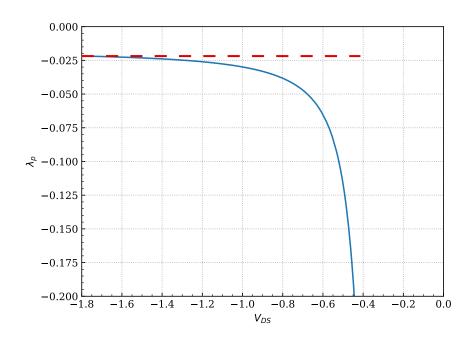


Figure 14: PMOS  $\lambda_p - V_{DS}$ 

### Problem 6

1. Small-signal Model

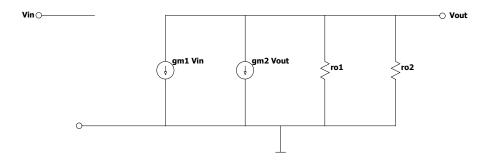


Figure 15: Small signal model

$$2. \ \lambda = 0V^{-1}$$

3. 
$$\lambda \neq 0V^{-1}$$

(a) 
$$A_V = \frac{v_{out}}{v_{in}}$$

$$-v_{out} = (g_{m1}v_{in} + g_{m2}v_{out})(r_{o1}//r_{o2})$$

$$-v_{in}g_{m1}(r_{o1}//r_{o2}) = (1 + g_{m2}(r_{o1}//r_{o2}))v_{out}$$

$$A_V = \frac{v_{out}}{v_{in}} = -\frac{g_{m1}}{g_{m2} + \frac{1}{r_{o1}} + \frac{1}{r_{o2}}}$$

(b) 
$$R_{out}$$

$$R_{out} = \frac{1}{g_{m2} + \frac{1}{r_{o1}} + \frac{1}{r_{o2}}}$$